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Substitute for form 1449A/PTO				Complete if Known					
INFO	RMATIO	N DIS	CLOSURE	Application Number	09/980,329				
STATEMENT BY APPLICANT				Date Filed:	March 5, 2002				
STATEMENT DI ALI EIOANI			LIOAII	First Named Inventor	Talish				
				Group Art Unit		·			
(use as many sheets as necessary)				Examiner Name					
Sheet	1	of	1	Attorney Docket Number	41482/205543				

Sheet	1	of 1		Attorne	y Docket	Number	41482	2/205543		
			U.S. P	ATENT D	OCUME	NTS				
Examine r Initials *	Cite No.1	Number - Kind Code ² (if known)	Publication Date MM-DD-YYYY		Name of Patentee or Applicant of Cited Document		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear			
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			FOR	FIGN PAT	ENT D	OCUMENT	s			
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Examiner Initials*	Cite No.1	Country Code ³ - Number ⁴ - Kir known)	d Code⁵ (if Publicatio MM-DD-¹		on Date YYYY			Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶	
M		WO 00/67846		11/16/	/2000 PC		СТ			
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